

High Dielectric Constant PvdF Films With Onium Compounds

ABSTRACT

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The present invention relates to a dielectric film comprising onium compound and polyvinylidene fluoride (PVDF). It further relates to a process for preparing the said dielectric films. The resulting dielectric films have very high dielectric properties, can be made thin, made excellent in winding property (flexibility) and assure a small dielectric loss.

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